

1 Measurements & Parameter Extraction

1.1 Line Width/Misalignment

1.1.1 Measured line widths

Nominal Linewidth	ACTV (dark field)	POLY (clear field)	CONT (dark field)	METAL (clear field)
$2\mu\text{m}$	3	4	1.869	2520

1.1.2 Misalignment

1.2 Four-Point Resistors [2a, 2b]

1.2.1 Measurement Setup

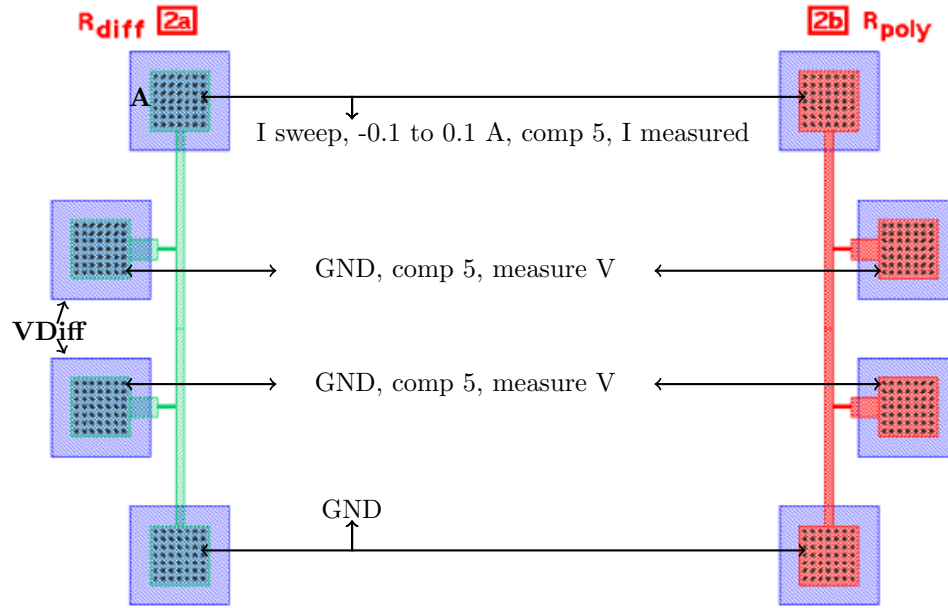


Figure 1: Device 2a is a diffusion resistor and 2b is a poly resistor.

1.2.2 I-V plot for the diffusion resistor, 2a

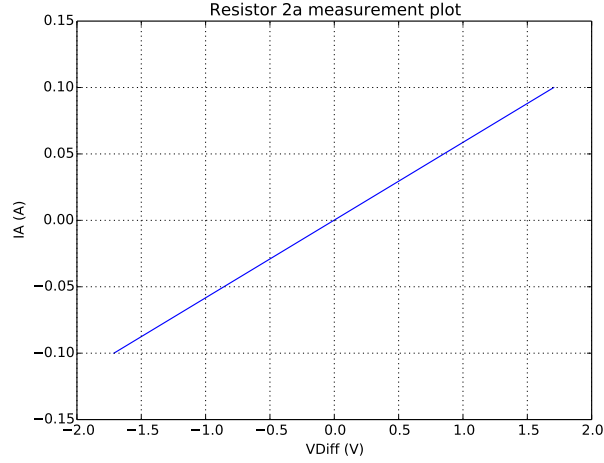


Figure 2: A plot of the measurement data taken for resistor 2a. The plot is based off of 2 data points.

From the plot above we can calculate our resistance. Note that the slope of the above plot will be equal to $1/R$. Since $I = V/R$, where I is our dependent variable (y axis) and V is our independent variable (X axis). A resistance of $R = 17 \Omega$ was calculated. Our width and length values are $10 \mu m$ and $200 \mu m$. This means that

$$R_s = \frac{W}{L} R_{\text{diff}} = \frac{10}{200} 17 = 0.85 \Omega$$

From the previous lab report we have a junction depth of $1 \mu m$. This means that our Resistivity is $\rho = R_s x_j = 0.85 \times 10^{-4} \Omega\text{-cm}$. Using the Irvin curves in Jaeger [1], we can estimate the surface concentration $N_0 \approx 10^{21}$. Now the mobility can be calculated using a table of values from Appendix xx.

$$\mu_e = \mu_{\min} + \frac{\mu_0}{1 + (N/N_{\text{ref}})^\alpha} = 92 + \frac{1268}{1 + (10^{21}/1.3 \times 10^{17})^{0.91}} = 92.37 \text{ cm}^2/\text{V} - s$$

1.2.3 I-V plot for the poly resistor, 2b

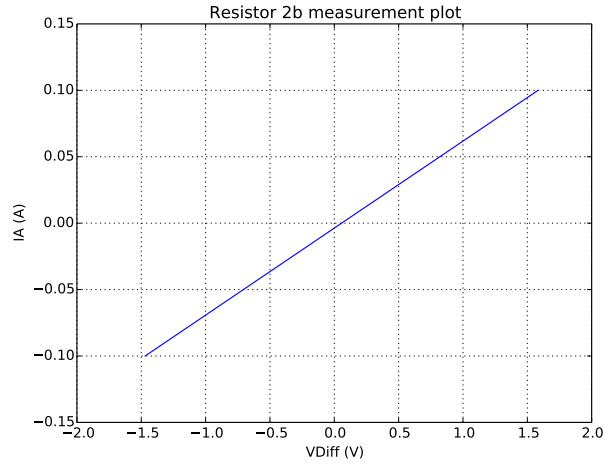


Figure 3: A plot of the measurement data taken for resistor 2b. The plot is based off of 2 data points.

From the plot above we calculate a $1/\text{slope}$ value of 15. Hence $R = 15 \Omega$. Our Resistivity is then $\rho = R_s t_{\text{poly}}$ where t_{poly} is the polysilicon thickness which is $0.4 \mu m$, Hence $\rho = 6 \Omega\text{-}\mu m$.

1.3 Four-Point Contact Resistor [17a, 17b]

1.3.1 Measurement Setup

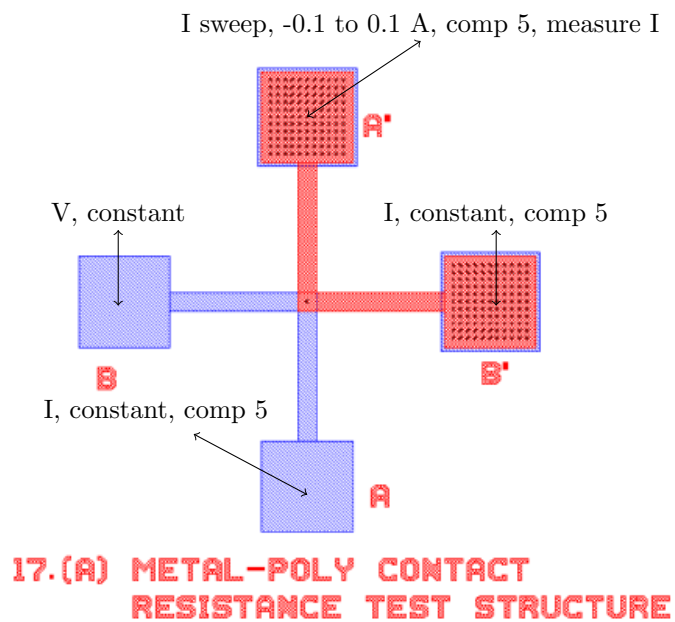


Figure 4: Measurement setup for 17a poly contact resistor. The same setup is used for the diffusion contact resistor, 17b.

1.3.2 I-V plot for 17a

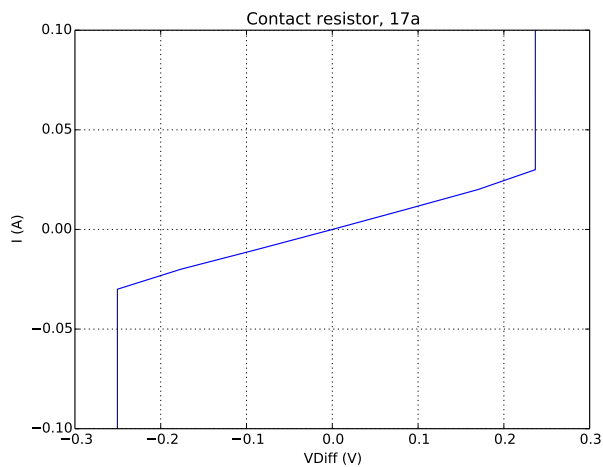


Figure 5: A plot of the measurement data taken for resistor 17a.

1.3.3 I-V plot for 17b

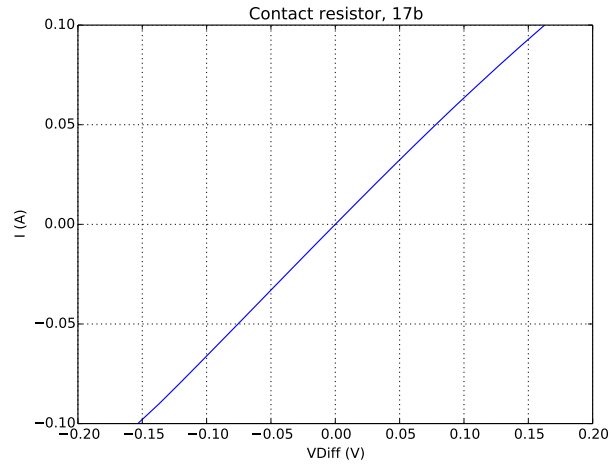


Figure 6: A plot of the measurement data taken for resistor 17b.

1.4 Four-Point Contact-Chain Resistor [2c, 2d]

1.4.1 Measurement Setup

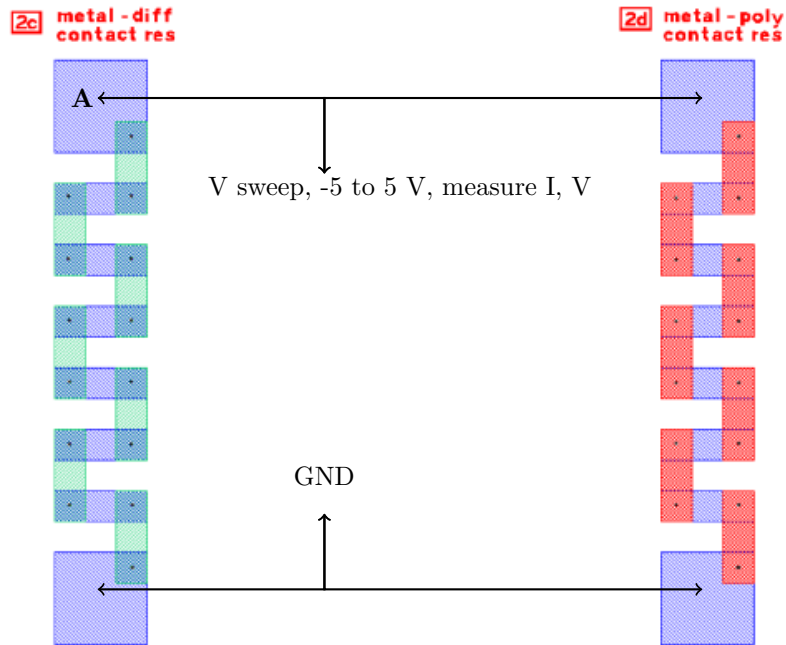


Figure 7: Chain resistor setup for diffusion and poly resistors.

1.4.2 b. I-V plot for diffusion resistor, 2c

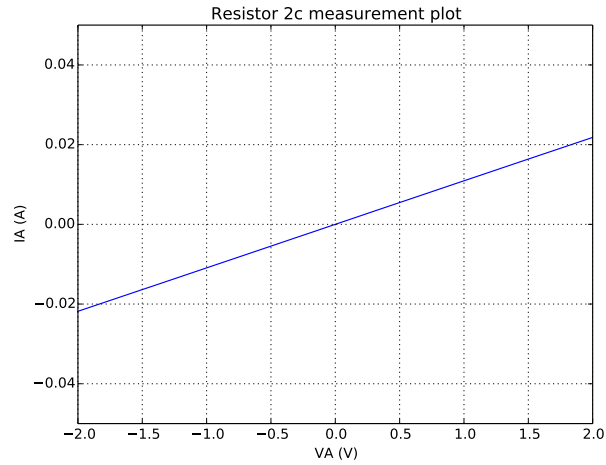


Figure 8: A plot of the measurement data taken for resistor 2c. The plot is based off of 2 data points.

- Extract the resistance
- Extract metal-to-diffusion contact resistance

1.4.3 b. I-V plot for poly resistor, 2d

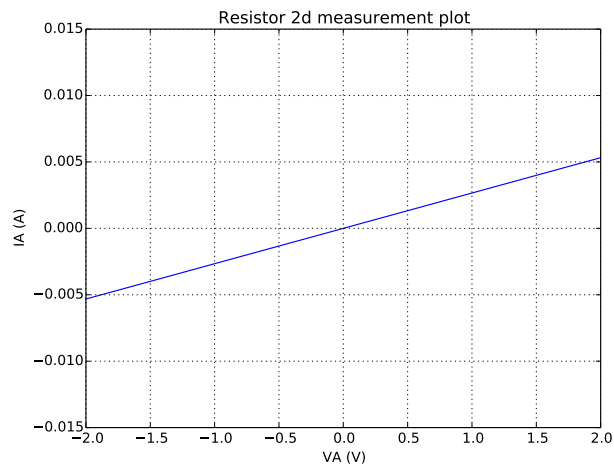


Figure 9: A plot of the measurement data taken for resistor 2d. The plot is based off of 2 data points.

- Extract the resistance
- Extract metal-to-poly contact resistance

1.5 Gate Oxide Capacitor, 4

1.5.1 Measurement Setup

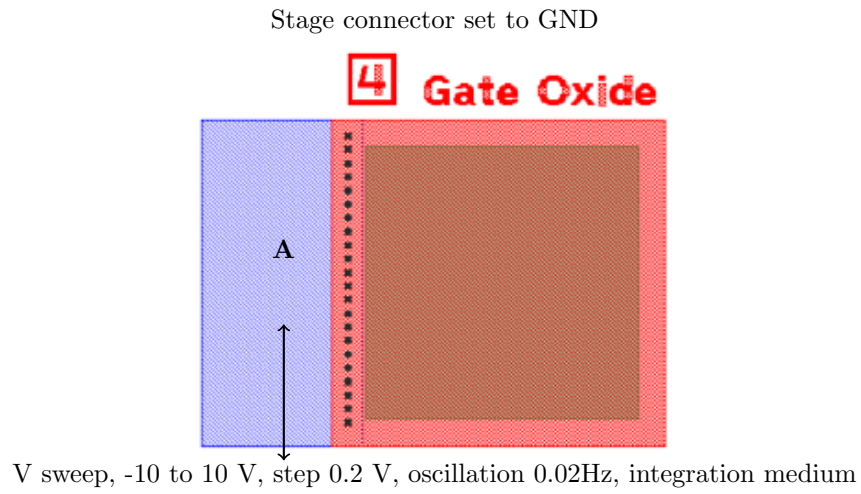


Figure 10: Gate capacitor setup.

1.5.2 C-V plot of gate oxide capacitor w/ lights ON

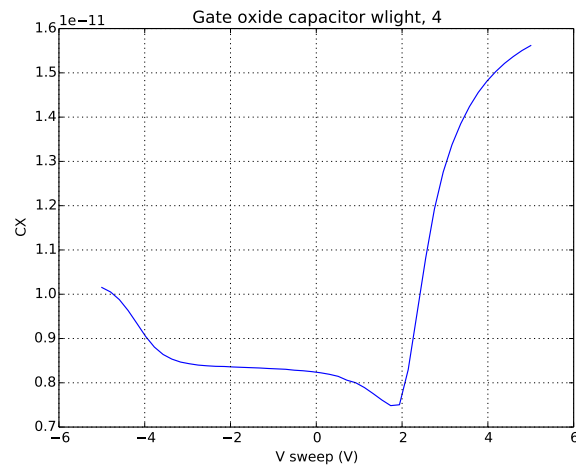


Figure 11: A plot of the measurement data taken for the gate capacitor, 4. Lights on.

Minimum capacitance

1.5.3 C-V plot of gate oxide capacitor w/ lights OFF

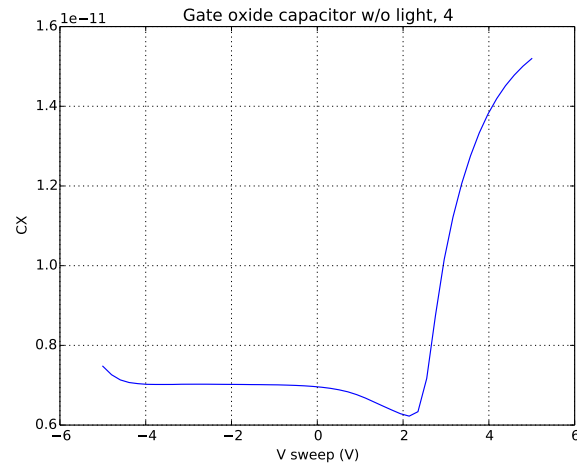


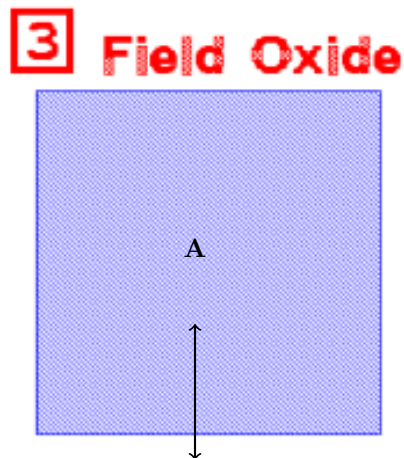
Figure 12: A plot of the measurement data taken for the gate capacitor, 4. Lights off.

minimum capacitance ...

1.6 Field Oxide Capacitor, 3

1.6.1 Measurement Setup

Stage connector set to GND



V sweep, -5 to 5 V, step 0.2 V, oscillation 0.02Hz, integration medium

Figure 13: Field oxide capacitor setup.

1.6.2 C-V plot of field oxide capacitor

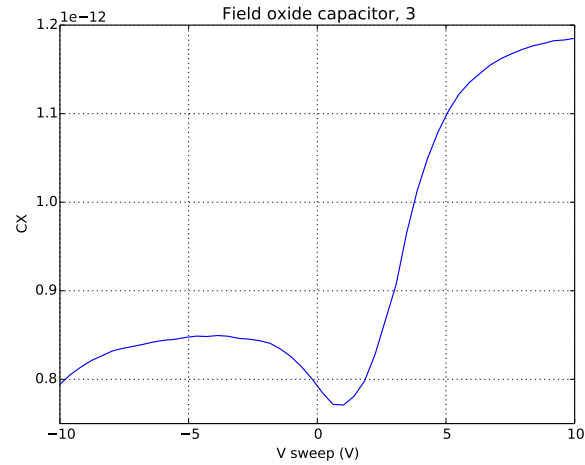


Figure 14: A plot of the measurement data taken for the field oxide capacitor, 3

Minimum capacitance

1.6.3 Capacitance in the accumulation region

minimum capacitance ...

1.6.4 Field oxide thickness

stuff...

1.7 Intermediate Oxide Capacitors, 5

1.7.1 Measurement Setup

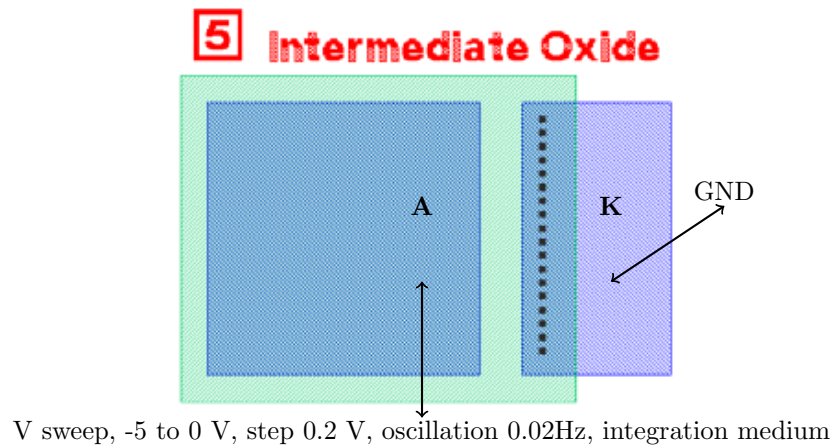


Figure 15: Intermediate oxide capacitor setup.

1.7.2 C-V plot of intermediate oxide capacitor

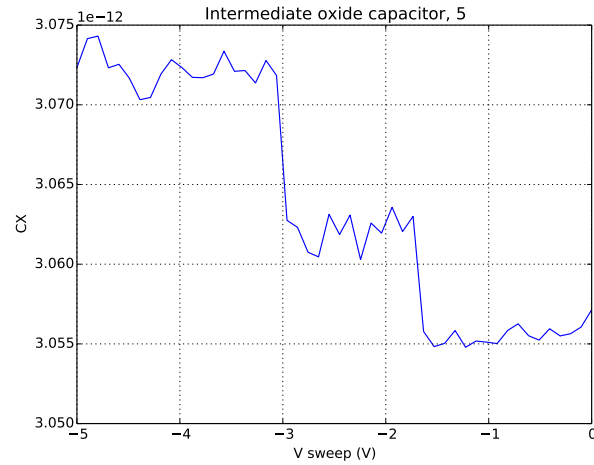


Figure 16: A plot of the measurement data taken for the Intermediate oxide, 5

stuff ...

1.7.3 Capacitance in the accumulation region

stuff...

1.8 Diode, 7

1.8.1 Measurement setups for forward and reverse operations

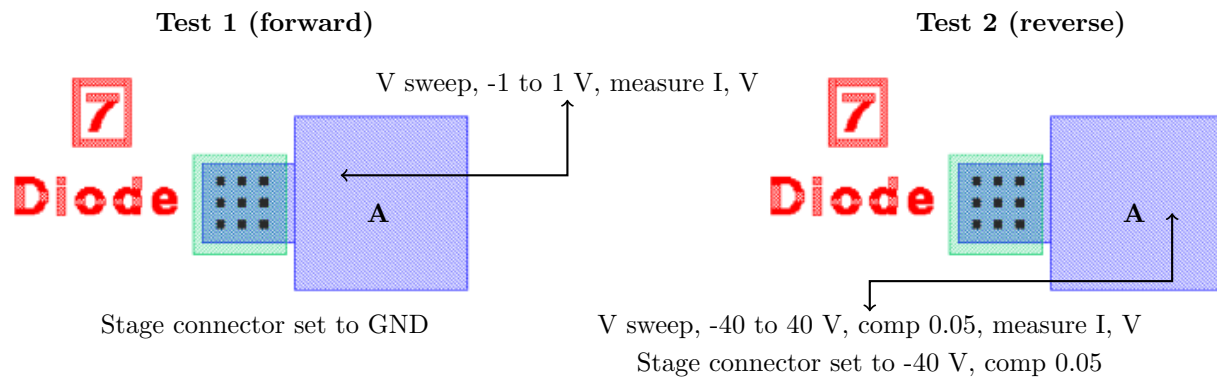


Figure 17: Two tests were performed on this diode; both measurement setups are shown above.

1.8.2 I-V plots for forward and reverse operation

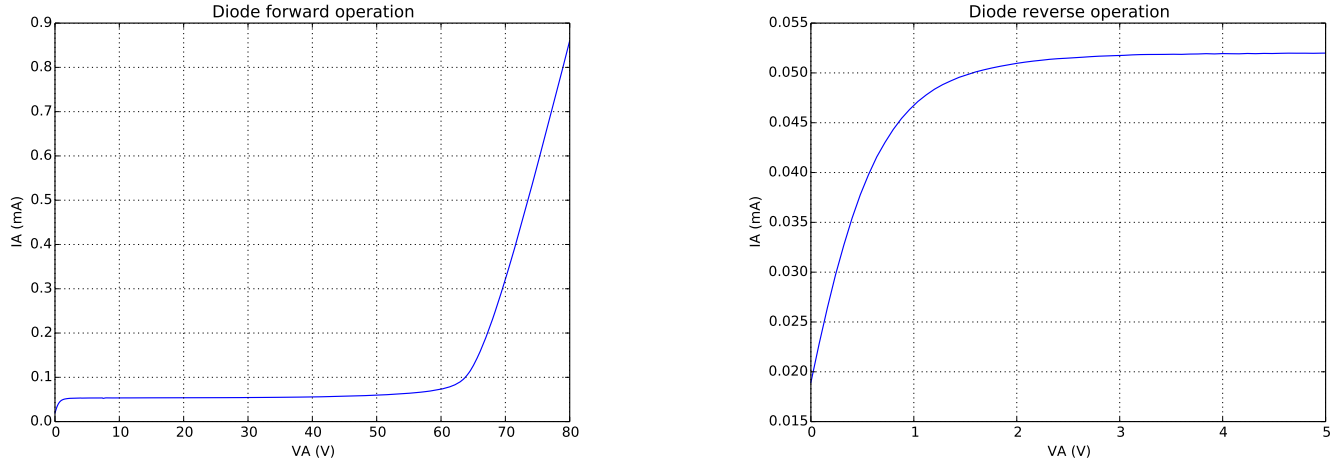


Figure 18: Plots of forward and reverse operation of Diode 7.

1.8.3 Extract the turn-on voltage and the series resistance

1.9 MOSFETs of Varying Length, [8a-d]

1.9.1 Measurement setups

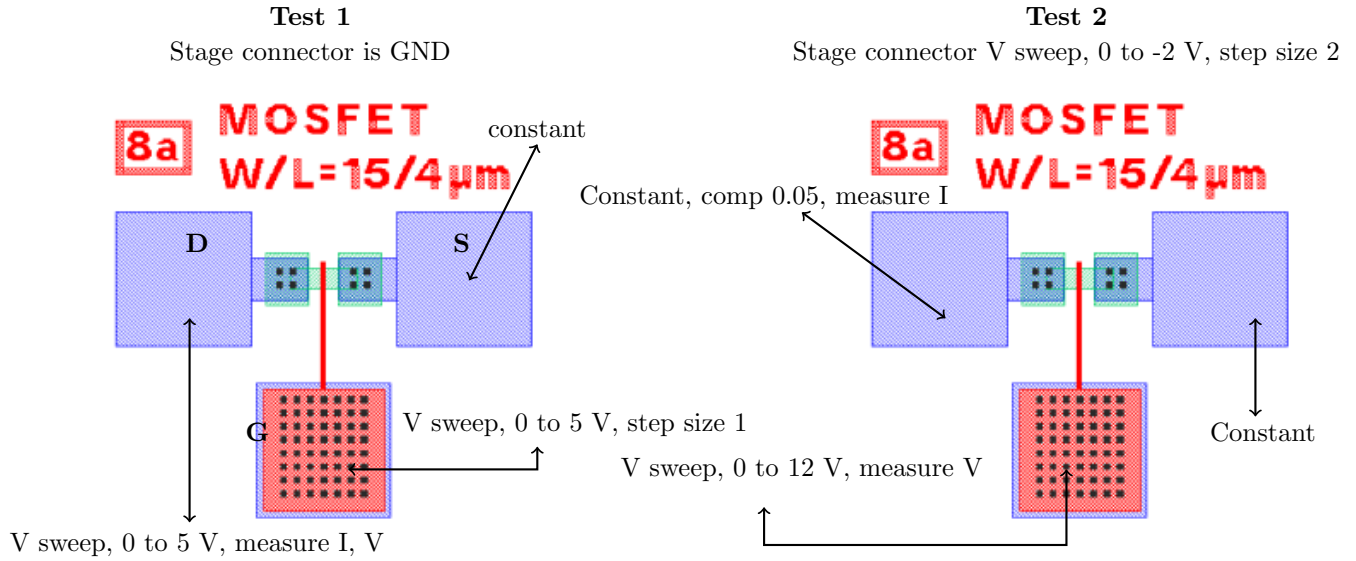


Figure 19: Measurement setup for Mosfet 8a. The same setup is used for Mosfets 8a-d. The only difference is the channel length which changes from 4 (8a) to 6 (8b) to 8 (8c) to 10 (8d) microns.

1.9.2 Plots of I_D - V_D , sweeping V_G

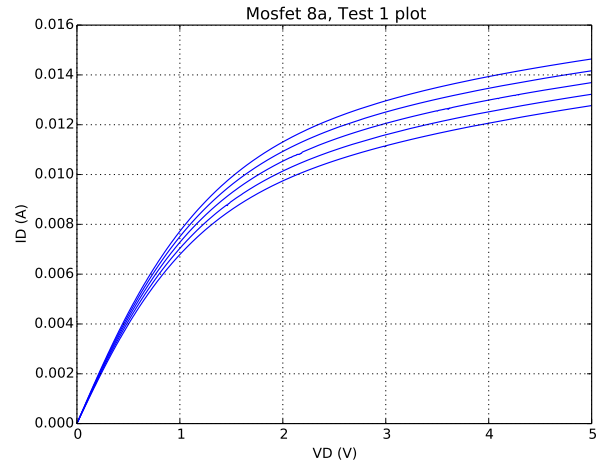


Figure 20: Test 1 for Mosfet 8a

Calculate stuff here...

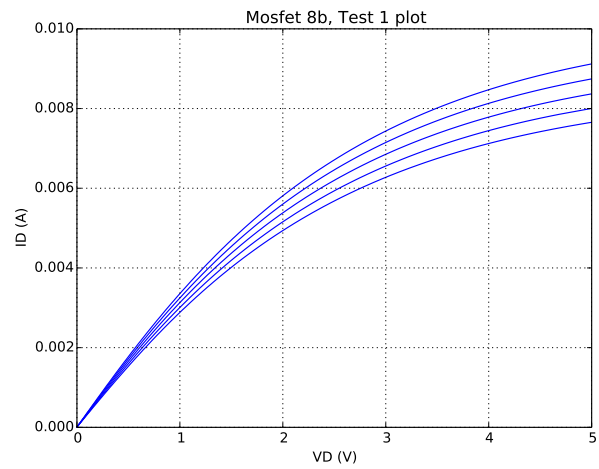


Figure 21: Test 1 for Mosfet 8b

Calculate stuff here...

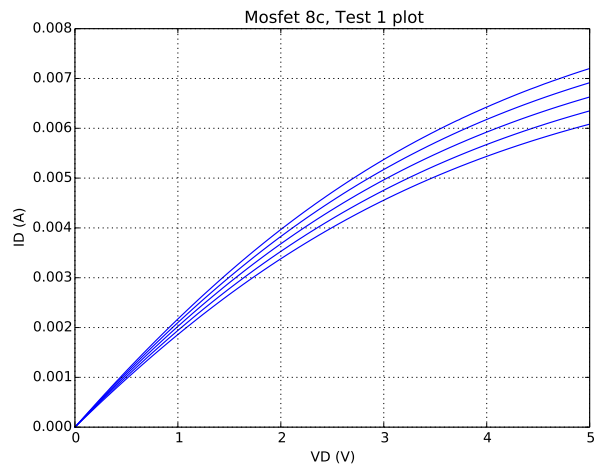


Figure 22: Test 1 for Mosfet 8c

Calculate stuff here...

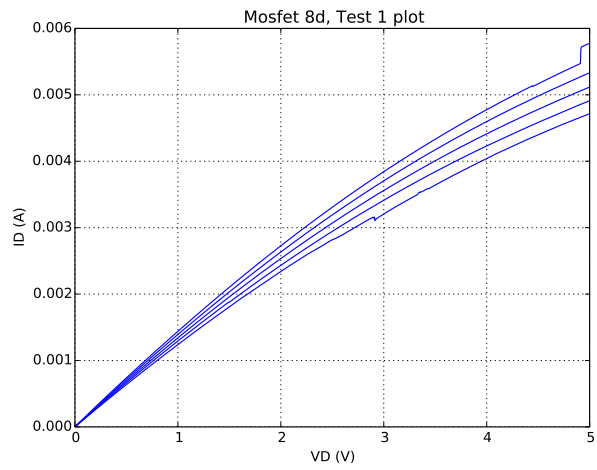


Figure 23: Test 1 for Mosfet 8d

Calculate stuff here...

1.9.3 Plots of I_D - V_G , sweeping V_B

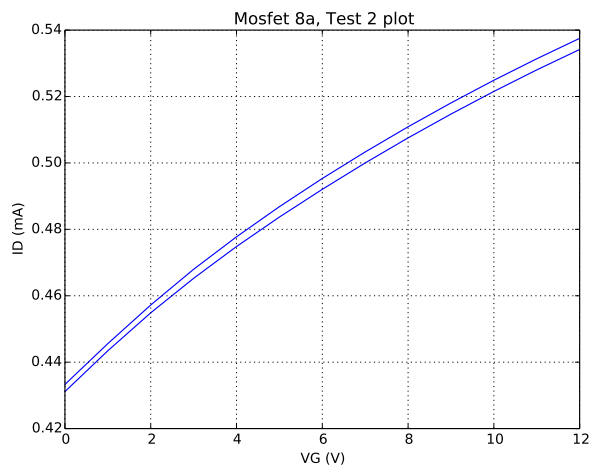


Figure 24: Test 2 for Mosfet 8a

Calculate stuff here...

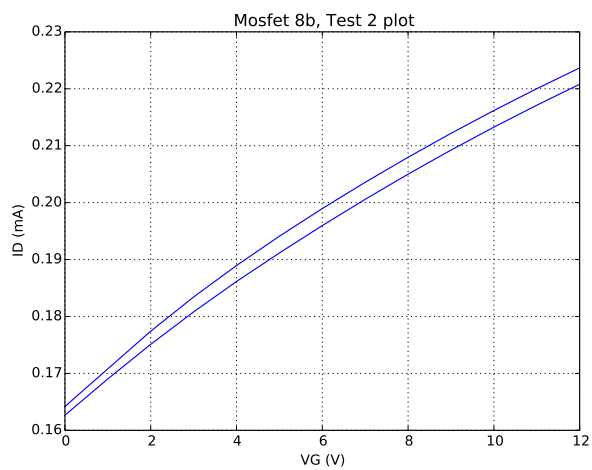


Figure 25: Test 2 for Mosfet 8b

Calculate stuff here...

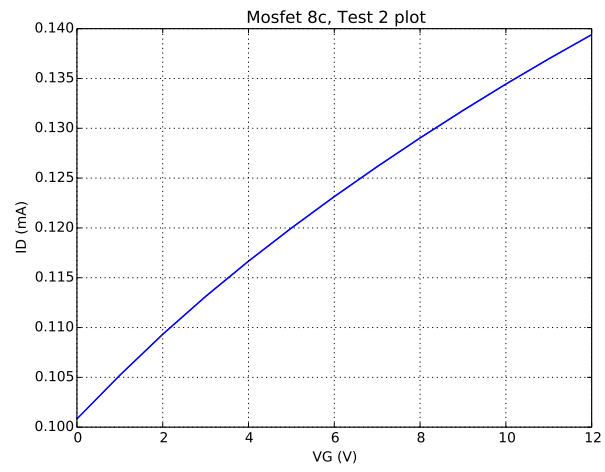


Figure 26: Test 2 for Mosfet 8c

Calculate stuff here...

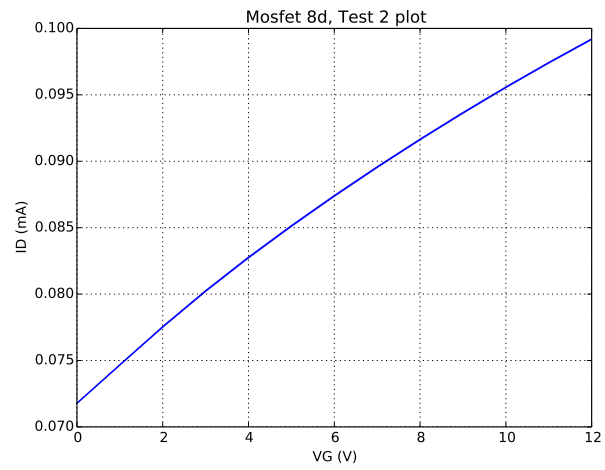


Figure 27: Test 2 for Mosfet 8d

Calculate stuff here...

1.10 MOSFETs of varying width [9a-c]

1.10.1 Measurement setup

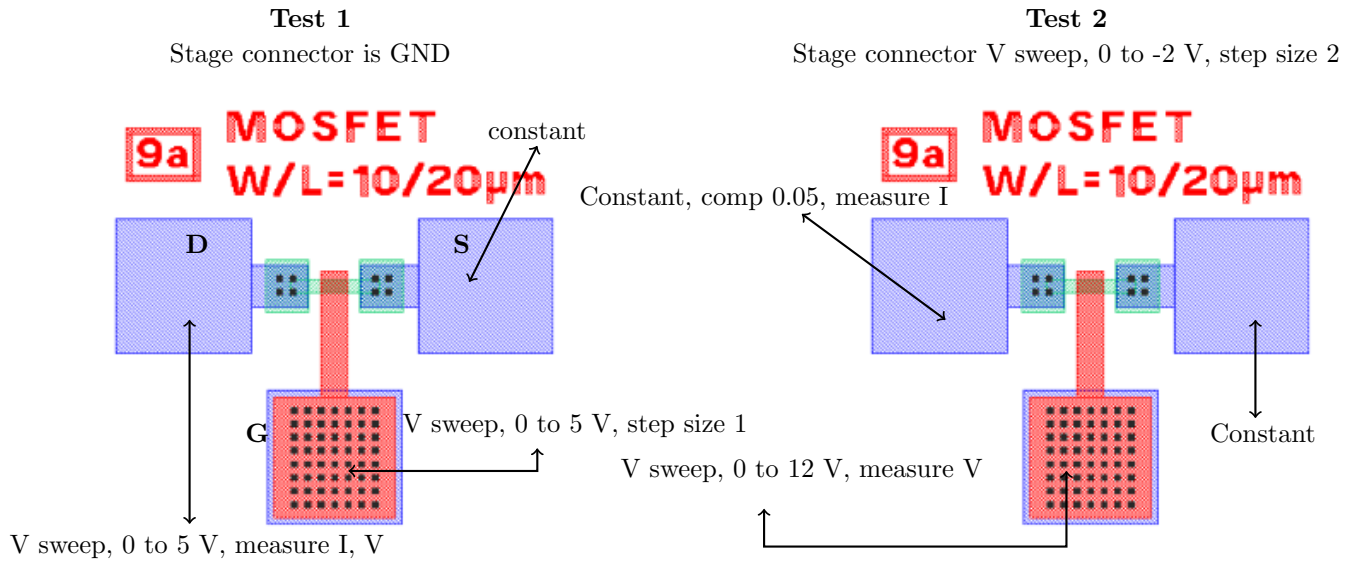


Figure 28: Measurement setup for Mosfet 9a. The same setup is used for Mosfets 9a-c. The only difference is the channel widths which changes from 10 (9a) to 15 (9b) to 20 (9c) microns.

1.10.2 Plots of I_D - V_D , sweeping V_G

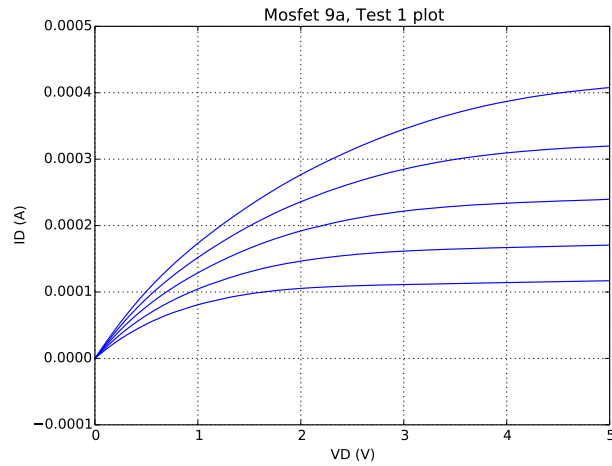


Figure 29: Test 1 for Mosfet 9a

Calculate stuff here...

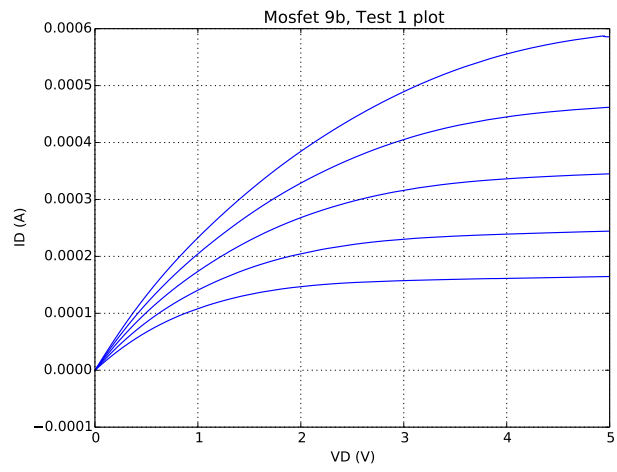


Figure 30: Test 1 for Mosfet 9b

Calculate stuff here...

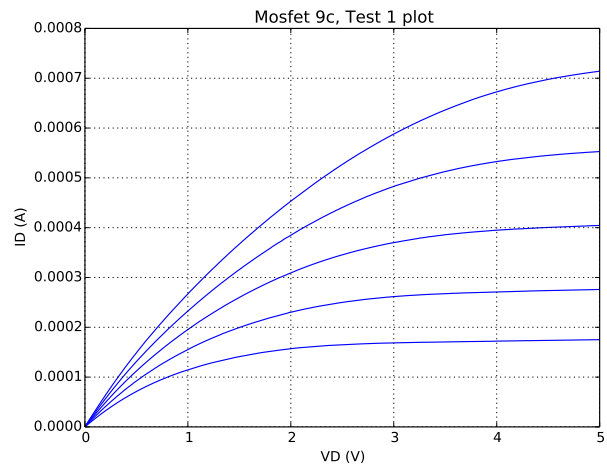


Figure 31: Test 1 for Mosfet 9c

Calculate stuff here...

1.10.3 Plots of I_D - V_G , sweeping V_B

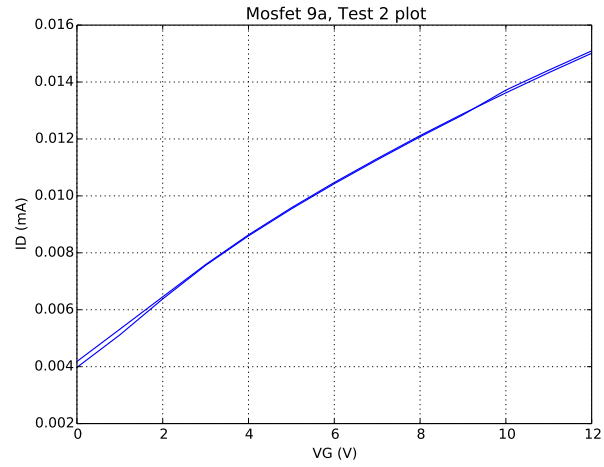


Figure 32: Test 2 for Mosfet 9a

Calculate stuff here...

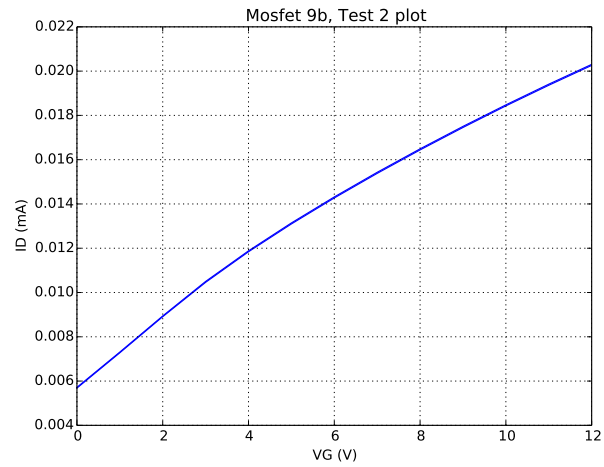


Figure 33: Test 2 for Mosfet 9b

Calculate stuff here...

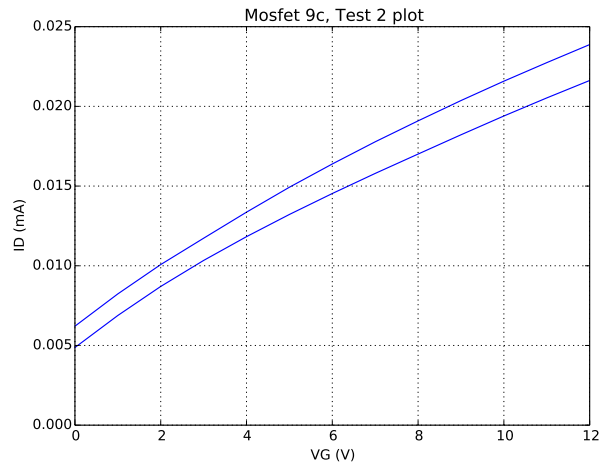


Figure 34: Test 2 for Mosfet 9c

Calculate stuff here...

1.11 Large MOSFET, 10

1.11.1 Measurement setup

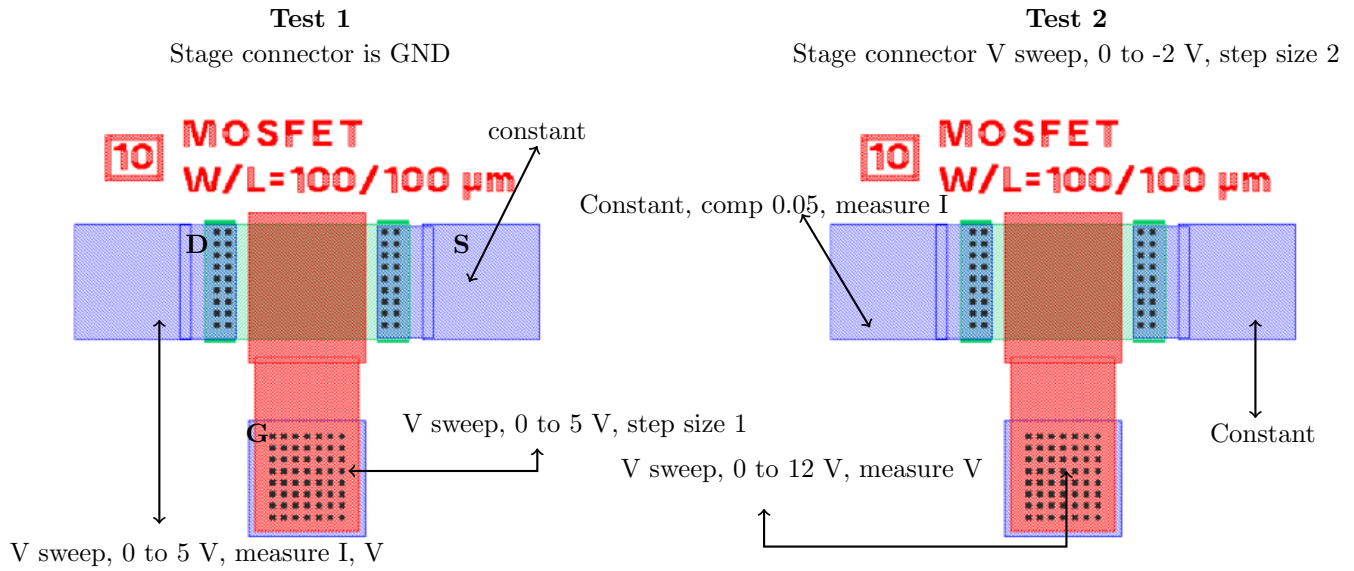


Figure 35: Measurement setup for Mosfet 10. This mosfet has very large dimensions compared to others.

1.11.2 Plots of I_D - V_D , sweeping V_G

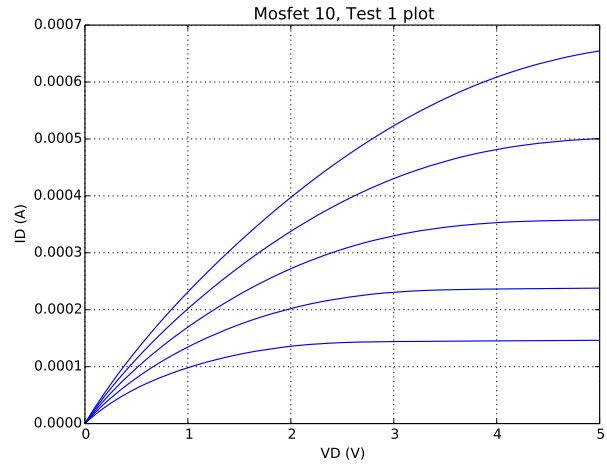


Figure 36: Test 1 for Mosfet 10

Calculate stuff here...

1.11.3 Plots of I_D - V_G , sweeping V_B

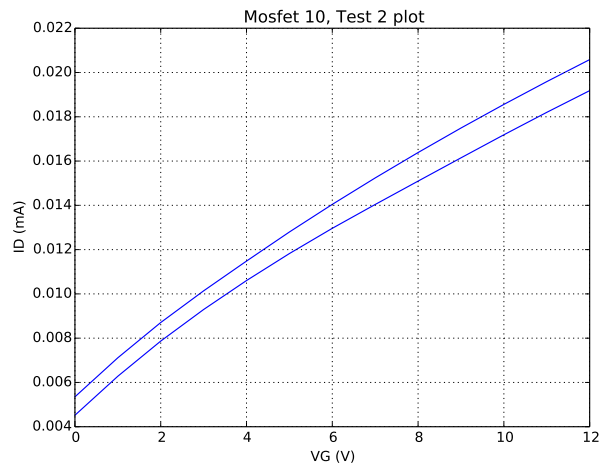


Figure 37: Test 2 for Mosfet 10

Calculate stuff here...

1.12 Inverter, 14

1.12.1 Measurement setup

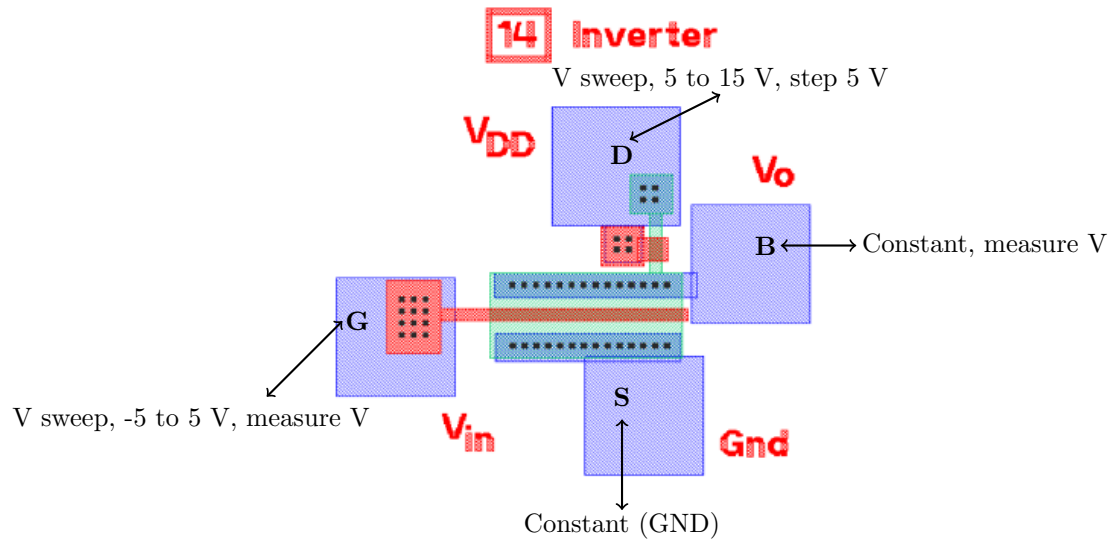


Figure 38: Setup for the inverter. Note that the source is connected to a GND and not the stage connector.

1.12.2 b. $V_{in} - V_{out}$ plot

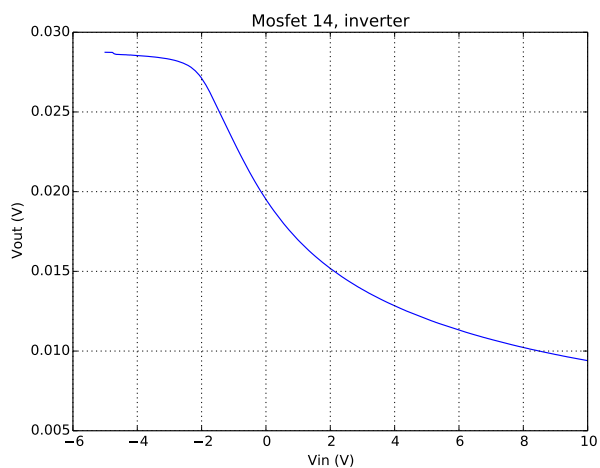


Figure 39: Plot for Inverter. Note both axis are in units of Volts.

1.12.3 Estimate V_M

calculations here....

2 Theoretical Calculations

2.1 Measured Physical Dimensions and Parameters

Parameter	Measured Value
Field t_{ox}	477.2 nm
Gate t_{ox}	86.5 nm
Intermediate t_{ox}	320 nm
X_j	1000 nm
$X_{j,\text{lateral}}$	880 nm
N_D	10^{21} cm^{-3}

2.2 Resistors [2a,2b]

2.3 Contact Resistances [17a,17b]

From jaeger Figure 7.6 [1] we that the specific contact resistivity $10^{-2} \mu\Omega\text{-cm}^2$. The contact area of resistors 17a and 17b is $5\mu\text{m}$ by $5\mu\text{m}$. This means the theoretical contact resistance for our contact resistors is

$$R_c = \frac{\rho_c}{A} = \frac{10^{-2} \mu\Omega - \text{cm}^2}{25\mu\text{m}} = \frac{10}{25} = 0.4\Omega$$

2.4 Contact-Chain Resistors [2c, 2d]

2.4.1 Diffusion chain resistor, 2c

R_c is the contact resistance calculated earlier and R_s is the sheet resistance calculate for the diffused resistor. η is a geometrical constant that has a value of 2.3

$$R_{\text{total}} = 7(\eta R_s + R_c) = 7((2.3)(R_s) + (0.4)) = ?$$

2.4.2 Poly chain resistor, 2d

R_c is the contact resistance calculated earlier and R_s is the sheet resistance calculate for the poly resistor. η is a geometrical constant that has a value of 2.3

$$R_{\text{total}} = 7(\eta R_s + R_c) = 7((2.3)(R_s) + (0.4)) = ?$$

2.5 Gate/Field Oxide Capacitors[3,4]

2.6 Diode

2.7 MOSFETs

2.7.1 MOSFETs of varying length [8] and width [9]

2.7.2 Large MOSFET

2.8 Inverter

3 Discussion

4 Optional Questions

5 Appendix

6 References

1. Jaeger, Richard. *Introduction to microelectronic fabrication*. New Jersey: Prentice Hall, 2002. Print.